Notice of Allowability	Application No.	Applicant(s)	
	10/770,245	YANG ET AL.	
	Examiner	Art Unit	
	David S. Blum	2813	
<u>·</u>	David S. Bluffi	2013	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF OF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED or other appropriate comming IGHTS. This application is	in this application. If not included nunication will be mailed in due co	l ourse. THIS
1. This communication is responsive to <u>6/23/05</u> .			
2. The allowed claim(s) is/are <u>1-12,14-19 and 21</u> .			
3. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).			
a) All b) Some* c) None of the:			
1. Certified copies of the priority documents have been received.			
2. Certified copies of the priority documents have been received in Application No			
3. Copies of the certified copies of the priority documents have been received in this national stage application from the			
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.			
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.			
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.			
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached			
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).			
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.			
*			•
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Attachment(s)	5 🗆 N (1)	(ID ((A II II (DTO	450)
1. Notice of References Cited (PTO-892)		nformal Patent Application (PTO-	-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)		Summary (PTO-413), ./Mail Date	
3. Information Disclosure Statements (PTO-1449 or PTO/SB/C	08), 7. ☐ Examiner'	s Amendment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛭 Examiner'	s Statement of Reasons for Allow	ance .
	9. 🗌 Other	·	
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This action is in response to the amendment filed 6/23/05.

Drawings

1. The drawings were received on 6/23/05. These drawings are acceptable.

Claim Rejections - 35 USC § 112

2. With the filed amendment of 6/23/05, the 35 U.S.C. 112 rejection is withdrawn.

Reasons for Allowance

- 3. Claims 1-12, 14-19, and 21 are allowed.
- 4. The following is an examiner's statement of reasons for allowance:

Claim 1 is allowed for reasons of record filed 6/23/05 by the applicant. In particular, claim 1 limits the method of manufacturing a semiconductor device to after implanting through the patterned mask, laterally diffusing the doped regions into the substrate, forming bitlines so that the forming and diffusing steps result in laterally diffused doped regions adjacent each bit lines that inhibit leakage current between adjacent pairs of buried bitlines. This limitation, in combination with the other limitations of claim 1 is not taught or suggested by the prior art of record. Kamal (US006479348B1) does not teach diffusing of the implant. Although it would be obvious to anneal the device of Kamal after implanting to repair damage from the implant, this would not inherently result in lateral diffusing and in laterally diffused doped regions adjacent each bit lines that inhibit

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leakage current between adjacent pairs of buried bitlines. Kamal is silent as to inhibiting leakage.

Claims 2-12, 14-19, and 21 are allowed as being properly dependent upon allowed claim 1.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to David S. Blum whose telephone number is (571)-272-1687) and e-mail address is David.blum@USPTO.gov.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr., can be reached at (571)-272-1702. Our facsimile number all patent correspondence to be entered into an application is (571) 273-8300.

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David S. Blum

September 1, 2005